

Application for Industrial Wastes Discharge Permit

Date February 5, 1980

No. 001-81-4

A. Name of Organization Fairchild Camera & Instrument Corporation

Address 464 Ellis Street, Mtn. View, Ca 94042

Address of Point of Discharge 545 Whisman Rd., Mtn. View, Ca Bldg. #1,2,3, & 4

2714

Individual Responsible Name Gregory Geary

Telephone (415) 962-4223

for industrial waste

Signature

Gregory Geary

(408) 371-3532

Attach Map Showing Point of Discharge, Sampling Points, and Waste Treatment Facility.

B. Flow Rate: Average 1,110,000 gals/day

Max. 1,220,000 gals/day

Peak Hourly 1150 GPM

C. Submit separate statement:

1. Detailing type of industry and nature of products
2. Listing chemicals used and approximate concentrations
3. Describing waste treatment facilities
4. Giving characteristics of exceptional industrial wastes
5. Concerning radioactive wastes
6. Naming organic solvents discharged and concentration at point of discharge

D. Indicate the point of discharge concentration of the following characteristics and mass emission rates where applicable.

|                                    |                 |                         |                   |
|------------------------------------|-----------------|-------------------------|-------------------|
| Biochemical oxygen demand (B.O.D.) | <u>10</u> mg/l  | Grease and oil, total   | <u>0</u> mg/l     |
| Chemical oxygen demand (C.O.D.)    | <u>12</u> mg/l  | Hydrogen Ion content pH | <u>5.5 - 10.0</u> |
| Total Solids, Average              | <u>100</u> mg/l | Fluoride                | <u>5.0</u> mg/l   |
| Suspended Solids, Average          | <u>10</u> mg/l  | Chlorine demand         | <u>5.0</u> mg/l   |
| Temperature                        | <u>60</u> °F    |                         |                   |

|                     | Max. Conc.<br>Allowable<br>mg/l | Allowable Mass<br>Emission Rate<br>kg/day |              | Max. Conc.<br>Allowable<br>mg/l | Allowable Mass<br>Emission Rate<br>kg/day |
|---------------------|---------------------------------|---|--------------|---------------------------------|---|
| Arsenic             | <u>0.1</u>                      | <u>0.01</u>                               | Formaldehyde | <u>5.0</u>                      | <u>0.5</u>                                |
| Barium              | <u>5.0</u>                      | <u>0.5</u>                                | Lead         | <u>0.5</u>                      | <u>0.05</u>                               |
| Beryllium           | <u>1.0</u>                      | <u>0.1</u>                                | Manganese    | <u>1.0</u>                      | <u>0.1</u>                                |
| Boron               | <u>1.0</u>                      | <u>0.1</u>                                | Mercury      | <u>0.05</u>                     | <u>0.005</u>                              |
| Chlorine            | <u>50.0</u>                     | <u>5.0</u>                                | Nickel       | <u>1.0</u>                      | <u>0.1</u>                                |
| Cadmium             | <u>0.1</u>                      | <u>0.01</u>                               | Chloroform   | <u>50.0</u>                     | <u>5.0</u>                                |
| Chromium Hexavalent | <u>1.0</u>                      | <u>0.1</u>                                | Phenols      | <u>1.0</u>                      | <u>0.1</u>                                |
| Chromium Total      | <u>2.0</u>                      | <u>0.2</u>                                | Selenium     | <u>2.0</u>                      | <u>0.2</u>                                |
| Cobalt              | <u>10.0</u>                     | <u>0.1</u>                                | Silver       | <u>5.0</u>                      | <u>0.5</u>                                |
| Copper              | <u>1.0</u>                      | <u>0.1</u>                                | Zinc         | <u>5.0</u>                      | <u>0.5</u>                                |
| Cresols             | <u>2.0</u>                      | <u>0.2</u>                                |              |                                 |   |
| Cyanides            | <u>1.0</u>                      | <u>0.1</u>                                |              |                                 |   |

NOT TO BE COMPLETED BY APPLICANT

Permit to Discharge Industrial Wastes in Accordance with This Application Approved

Subject to Attached General and Specific Conditions

Allen Shelley, Director of Public Works

Signature

Allen Shelley

Date

2-5-80

Permit to Discharge Exceptional Industrial Waste Approved

List Details:

Allen Shelley, Director of Public Works

Signature

Date

DISTRIBUTION: Original to Industrial Waste File, Copy to Discharger, Copy to Water Quality Control Plant, Copy to Palo Alto, Copy to Sewer Division.

CITY OF MOUNTAIN VIEW

Industrial Waste Discharge Permit

DATE: February 5, 1980

NO. 001-81-4

NAME OF ORGANIZATION: Fairchild Camera & Instrument Corporation

ADDRESS: 464 Ellis Street, Mountain View, Calif. 94043

GENERAL CONDITIONS

1. This permit is issued under the ordinances and regulations of the City of Mountain View currently in effect, but all discharges hereunder shall comply with all ordinances and regulations of the City and all other applicable local, state, and federal regulations, whether now in effect or hereafter adopted or amended.
2. Any violation of the terms of this Permit or the ordinances or regulations of the City shall be grounds for revocation.
3. If any proposed revisions in plant operations are expected to cause significant changes in waste water quality or quantity (25 percent or more, or 25,000 gallons per day) from that given in approved Permit information, an application for an amended permit must be submitted for approval detailing the nature of the changes.
4. In accordance with Section 35.32.8 of the City Code, accidental discharges of industrial wastes shall be reported immediately to the Public Works Department, telephone number 967-7211, Ext. 270, during normal office hours, or to the Fire Department, telephone number 968-4415, on holidays or after normal office hours AND to the Palo Alto Regional Water Quality Control Plant, telephone number 329-2598 so that appropriate countermeasures may be taken.
5. This Permit is not transferable without prior written consent of the Director of Public Works. In general, a change of ownership will require a new permit.
6. The issuance of this permit does not constitute a warranty that the design capacity of the sewage collection and treatment system is sufficient to accommodate peak sewage flows from all dischargers who may now or hereafter be connected to the system. Pursuant to Sec. 35.32.1(d) the City reserves the right to impose restrictions on sewage discharges where necessary in the judgment of the City to assure the proper functioning in the sewerage system.

SPECIFIC CONDITIONS

1. This permit is for a period ending on April 1, 1981 if significant progress has been made in reducing total plant flow and approved pre-treatment facilities have been installed.
2. This permit applies to industrial waste discharges at the following location(s) only:  
545 Whisman Road  
Buildings 1, 2, 3 and 4
3. Your attention is called to the fact that flow rates shown on the permit application exceed per-acre design flows of the sewers serving the above locations. Restrictions or additional charges may be imposed in accordance with Sec. 35.32.1(j) of the City Code should peak sewage flows from the total upstream acreage approach the capacity of these sewers.

APPLICATION FOR INDUSTRIAL WASTES DISCHARGE PERMIT, ITEM C.

1. Type of Industry and Nature of Products

Fairchild Semiconductor processes silicon metal into electronic semiconductor devices.

2. Chemicals used in semiconductor device processing are:

Gases

Nitrogen  
Hydrogen  
Oxygen  
Argon  
Hydrogen chloride  
Chlorine  
Compressed air  
Ammonia

Liquids

Sulfuric acid  
Nitric acid  
Hydrofluoric acid  
Hydrochloric acid  
Acetic acid  
Phosphoric acid  
Ammonium fluoride  
Ammonium hydroxide  
Acetone

Liquids

Methanol  
Isoperpanol  
Methylene chloride  
Trichloroethane  
Detergents  
Aluminum sulfate  
Sodium carbonate  
Sodium hydroxide  
Freon  
Glycerin  
Xylene

3. Waste Treatment Facilities

Neutralization of acids is provided by injection of NaOH and/or H<sub>2</sub>SO<sub>4</sub> into mixing tanks with continuous monitoring and control. Fluoride solutions are captured and disposed of separately, not into the city sewer.

4. Characteristics of exceptional industrial wastes. None.

No radioactive wastes are discharged.

Organic solvents are captured for storage and recycling.



36 Systems Tech  
1725 Technology Drive  
San Jose, CA 95110

80 Diode Plant  
4300 Redwood Hwy.  
San Rafael, CA - 1903

30 Palo Alto Facility  
4001 Miranda Avenue  
Palo Alto, CA 94304

25 Healdsburg Facility  
33 Healdsburg Avenue  
Healdsburg, CA 95448

42 South San Jose Facility  
101 Bernal Road  
San Jose, CA 95139

46 Exatron Plant  
3105 Alfred Street  
Santa Clara, CA 95050

Middlefield Road

Whisman Road

441

369

19

13

23

345

1

2

Translator Plant

3

4

313

Plant Protection

Parking Deck

9

Chem Mix  
D.I. Plant

401

Credit Union

21

640

18

Filing

644

National Avenue

Fairchild Drive

20

Headquarters

464

6

423

7

465

22

450

National Avenue

Ellis Street

401

14



FAIRCHILD MOUNTAIN VIEW COMPLEX

Security Department - 4/76

ADDITIONAL INFORMATION REGARDING THE I.W. PERMIT  
FOR BUILDING 1, 2 & 3

- (1) The LIC relocation to Building 1 will remove production at Building 20, resulting in a transfer of water flow within the Mountain View complex (not a water flow increase).
- (2) The conversion from 3" to 4" wafers by LIC will result in a 44% increase in production with no increased labor or water usage.
- (3) A BPM group will move from Building 20 to the South San Jose facility in the second quarter of 1980, eliminating the flow from this operation.
- (4) The BPM operations that remain in Mountain View will convert from 3" to 4" wafers, resulting in a 44% production increase with no increased labor or water usage.
- (5) The Transistor group will be moving to the San Rafael facility, resulting in the elimination of flow from this operation.
- (6) A 6 month feasibility study will be performed on 300 gpm D.I. Water reclaim and 600 gpm treated effluent reclaim.
- (7) Pending favorable completion of the feasibility studies, construction of the above reclaim systems will take an estimated 2 years (depending upon economic climate).
- (8) The projected flow rates from the new system were based on peak water usage at full production rates, actual flow rates will be less.
- (9) The relocation of LIC at Building 1 will not be fully operational until 1-2 years after start-up.
- (10) Actual flow rates can only be measured after the system is installed. Loss of water via cooling towers is known to be significant.
- (11) Planning is under way to convert to 5" wafers. This would yield a 63% production increase over today's output without increasing labor or water usage.
- (12) The vast majority of construction projects at FC & I are based on technological advances to increase yields, not new production that requires more labor or water usage.
- (13) Even without the above, the new neutralization pit would not increase our total water discharge but would tend to only balance the discharge from two locations.